

Supporting Information

PECVD of Hexamethyldisiloxane Coatings Using Extremely Asymmetric Capacitive RF Discharge

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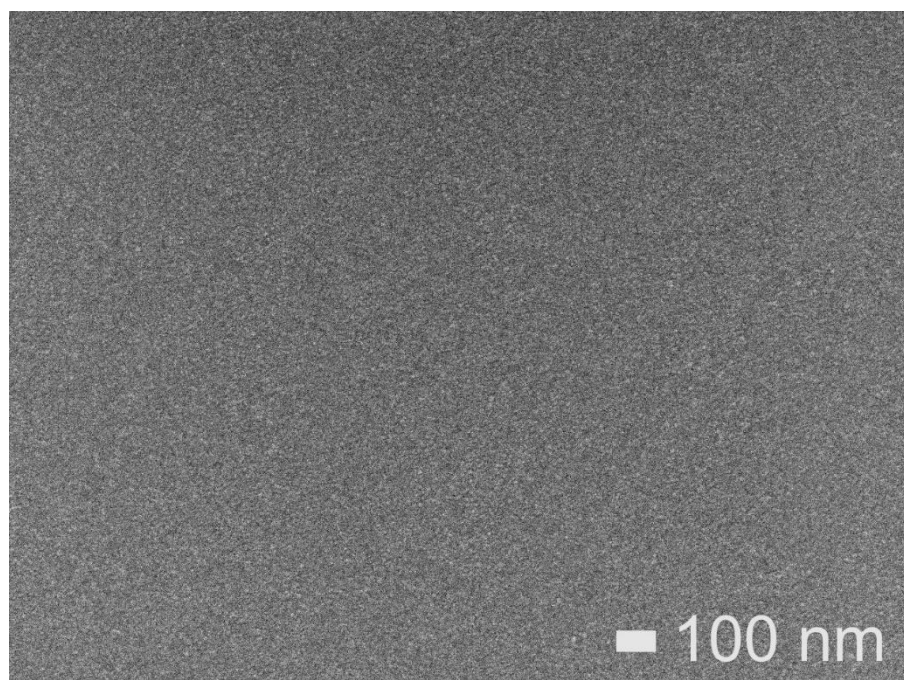


Figure S1. SEM image of the HMDSO coating.



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